

Title (en)

SEMICONDUCTOR DEVICE INCLUDING A FLOATING GATE MEMORY CELL WITH A SUPERLATTICE CHANNEL AND ASSOCIATED METHODS

Title (de)

HALBLEITERBAUELEMENT MIT FLOATING-GATE-SPEICHERZELLE MIT EINEM ÜBERGITTERKANAL UND ENTSPRECHENDE VERFAHREN

Title (fr)

DISPOSITIF A SEMI-COMDUCTEUR COMPORTANT UNE CELLULE DE MEMOIRE A GRILLE FLOTTANTE AVEC UN CANAL DE SUPER-RESEAU ET PROCEDES ASSOCIES

Publication

**EP 2016624 A1 20090121 (EN)**

Application

**EP 07761833 A 20070503**

Priority

- US 2007068155 W 20070503
- US 38178706 A 20060505
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Abstract (en)

[origin: WO2007131117A1] A semiconductor device may include a semiconductor substrate (21) and at least one non-volatile memory cell. The at least one memory cell may include spaced apart source and drain regions (26,27), and a superlattice channel (25) including a plurality of stacked groups of layers on the semiconductor substrate between the source and drain regions. Each group of layers of the superlattice channel may include a plurality of stacked base semiconductor monolayers defining a base semiconductor portion and an energy band-modifying layer thereon, which may include at least one non-semiconductor monolayer constrained within a crystal lattice of adjacent base semiconductor portions. A floating gate (37) may be adjacent the superlattice channel, and a control gate (38) may be adjacent the second gate (38) insulating layer.

IPC 8 full level

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CPC (source: EP)

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